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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/496,794	02/02/2000	John T. Moore	MICT-0005-D1-US	6700	
7590 05/31/2005			EXAM	EXAMINER	
Trop Pruner & Hu			OWENS, DOUGLAS W		
8554 Katy Free Suite 100	way		ART UNIT	PAPER NUMBER	
Houston, TX 77024			2811		
			DATE MAILED: 05/31/2003	DATE MAILED: 05/31/2005	

Please find below and/or attached an Office communication concerning this application or proceeding.

<b>&gt;</b>		Ē	1		
	Application No.	Applicant(s)	_		
	09/496,794	MOORE ET AL.			
Office Action Summary	Examiner	Art Unit	_		
	Douglas W. Owens	2811			
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespondence address	_		
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply is specified above, the maximum statutory period of Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be timer within the statutory minimum of thirty (30) day will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).			
Status					
1) Responsive to communication(s) filed on 07 M	arch 2005.				
2a)⊠ This action is <b>FINAL</b> . 2b)☐ This	This action is FINAL. 2b) This action is non-final.				
3) Since this application is in condition for allowar	· · · · · · · · · · · · · · · · · · ·				
closed in accordance with the practice under E	x parte Quayle, 1935 C.D. 11, 45	53 O.G. 213.			
Disposition of Claims					
4)⊠ Claim(s) <u>26-30</u> is/are pending in the application 4a) Of the above claim(s) is/are withdraw					
5) Claim(s) is/are allowed.					
6)⊠_ Claim(s)- <u>26-30</u> -is/are rejected.		•			
7) Claim(s) is/are objected to.					
8) Claim(s) are subject to restriction and/or	r election requirement.				
Application Papers					
9) The specification is objected to by the Examine	r.				
10) ☐ The drawing(s) filed on is/are: a) ☐ acce			4		
Applicant may not request that any objection to the	,				
Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the Ex					
Priority under 35 U.S.C. § 119					
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of:		-(d) or (f).			
<ol> <li>Certified copies of the priority documents</li> <li>Certified copies of the priority documents</li> </ol>		on No			
3. Copies of the certified copies of the prior	· ·				
application from the International Bureau	·	a in this realistic stage			
* See the attached detailed Office action for a list	• • • • • • • • • • • • • • • • • • • •	d.			
Attachment(s)					
1) Notice of References Cited (PTO-892)	4) Interview Summary				
<ul> <li>2) Notice of Draftsperson's Patent Drawing Review (PTO-948)</li> <li>3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)</li> </ul>	Paper No(s)/Mail Da 5) Notice of Informal P	ite atent Application (PTO-152)			

U.S. Patent and Trademark Office PTOL-326 (Rev. 1-04)

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### **DETAILED ACTION**

## Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 2. Claims 26 30 are rejected under 35 U.S.C. 102(e) as being anticipated by US Patent No. 6,727,569 to Gardner et al.

Regarding claims 26, 28 and 30, Gardner et al. teach a semiconductor structure (Fig. 9), comprising:

- a support (102);
- a first material (104) deposited on the support;
- a trench formed through the first material and into the support; and
- a trench filler material (110) deposited in the trench, the trench filler material inherently having an etch rate that is less than 1.2 time the first etch rate and substantially similar to the first etch rate, since both materials are the same and deposited by CVD (Col 4, lines 8 and 9; Col. 5, lines 45 48), the semiconductor structure having a planar exposed upper surface formed of the first material and the trench filler material.

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Regarding claim 27, Gardner et al. teach a semiconductor structure, wherein the first material is deposited by chemical vapor deposition. With respect to the source of the material being from tetraethyorthosilicate or a silane and oxygen system, this is considered a product-by-process limitation. "Even though product-by-process claims are limited by and defined by the process, determination of patentability is based on the product itself. The patentability of a product does not depend on its method of production. If the product in the product-by-process claim is the same as or obvious from a product of the prior art, the claim is unpatentable even though the prior product was made by a different process." In re Thorpe, 777 F.2d 695, 698, 227 USPQ 964, 966 (Fed. Cir. 1985).

Regarding claim 29, Gardner et al. teach a semiconductor structure, wherein the trench filler material includes silicon dioxide deposited from tetraethyorthosilicate (Col. 5, lines 45 – 48).

## Response to Arguments

3. Applicant's arguments with respect to claims 26 – 30 have been considered but are most in view of the new ground(s) of rejection.

### Conclusion

4. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

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A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Douglas W. Owens whose telephone number-is 571-272-1662. The examiner can normally be reached on Monday-Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Eddie C. Lee can be reached on 571-272-1732. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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Douglas W Owens Examiner

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